

INFORMATION DISCLOSURE STATEMENT		Atty. Docket No.: 52314US016		Serial No.: to be assigned		
		Applicant(s): Gunter A. Kohler et al.				
		Filing Date: even date herewith		Group: ---		
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Examiner Initial	Document Number	Date	Name	Class	SubClass	Filing Date of Approval
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EXAMINER

A. Michael Howell

Date Considered

02-04-03

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